

L Number	Hits	Search Text	DB	Time stamp
1	20647	((plasma or dry) near5 (remov\$3 etch\$3)) near15 (sacrificial photoresist resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 13:38
8	20710	MEMS or microelectromechanical or micromechanical or (micro adj (machin\$3 or mechanical or electromechanical or (electro adj mechanical) or fabricat\$3)) or micromachin\$3 microfabricat\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 13:41
15	2797	((((plasma or dry) near5 (remov\$3 etch\$3)) near15 (sacrificial photoresist resist)) near20 (opening hole))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 13:43
22	153	(MEMS or microelectromechanical or micromechanical or (micro adj (machin\$3 or mechanical or electromechanical or (electro adj mechanical) or fabricat\$3)) or micromachin\$3 microfabricat\$3 and (((plasma or dry) near5 (remov\$3 etch\$3)) near15 (sacrificial photoresist resist)) near20 (opening hole))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 13:46
29	864	438/50-53.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 13:50
36	0	438/50-53.icls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 14:15
43	94	((((plasma or dry) near5 (remov\$3 etch\$3)) near15 (sacrificial photoresist resist)) and 438/50-53.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 13:51
50	20	(((((plasma or dry) near5 (remov\$3 etch\$3)) near15 (sacrificial photoresist resist)) near20 (opening hole)) and 438/50-53.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 13:51
57	424	438/725.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 14:15
64	60	(((((plasma or dry) near5 (remov\$3 etch\$3)) near15 (sacrificial photoresist resist)) near20 (opening hole)) and 438/725.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 14:15
71	15	(MEMS or microelectromechanical or micromechanical or (micro adj (machin\$3 or mechanical or electromechanical or (electro adj mechanical) or fabricat\$3)) or micromachin\$3 microfabricat\$3) and 438/725.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/27 14:16